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Internal Nucleophilic Displacements within Silanolate lons. A New Mechanism of Substitution at Silicon

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Unimolecular dissociation of $\neg O_{-}(X)Si < species to give X^{-} and O=Si < (which immediately reacts with the solvent) is postulated to account for (a) features of the base-catalysed cleavage of R-Si bonds in solutions of RSiMe₂OMe (R = m-ClC₆H₄CH₂ or PhC=C) in 5% H₂O-MeOH and (b) the rapid conversion of (Me₃Si)₃-CSiPh(OH)I into (Me₃Si)₃CSiPh(OH)(OMe) by methanolic MeONa.$

We present evidence for a new mechanism of substitution at silicon. This mechanism has been detected in solvolysis under basic conditions of organosilicon species in which a hydroxygroup is present on the silicon bearing the leaving group X, and, as depicted in Scheme 1, involves an internal displacement within a silanolate ion to give a silanone, which reacts rapidly with the solvent (*e.g.* MeOH) to give the same product as would be expected for direct nucleophilic displacement of X.

We first suspected the existence of this mechanism when we

$$\begin{array}{ccc} OH & O_{\overline{1}} \\ I & B & I \\ R_2 Si - X \xrightarrow{BH^+} R_2 Si - X \longrightarrow R_2 Si = O + X^- \quad (slow) \end{array}$$

 $R_2Si=O + MeOH \longrightarrow R_2Si(OH)(OMe)$ (rapid)

Scheme 1



Figure 1. Plot of observed first-order rate constant, k, against the base concentration for cleavage of m-ClC₈H₄CH₂SiMe₂OMe at 50.0 °C in (a) MeOH (squares) and (b) 5 vol-% H₂O-MeOH (circles). The curve in case (b) is that generated by equation (1).

measured spectrophotometrically the rate of base-catalysed cleavage of the R-Si bonds of RSiMe₂OMe species in MeOH and in 5 vol-% H_2O -MeOH. For R = m-ClC₆ H_4CH_2 (initially 5×10^{-3} M) in MeOH the dependence of the observed firstorder rate constant, k, at 50.0 °C on the base concentration was similar to that observed for cleavage of RSiMe₃ species,¹ but in the water-containing medium the dependence was very different, the value of k rising sharply with increasing base at low base concentrations and then levelling off (see Figure 1). We were aware that some of the RSiMe₂OMe would be rapidly converted into the silanol RSiMe₂OH and hence into RSiMe₂- O^- in 5% H₂O-MeOH containing base, but expected that the rate of cleavage of the silanol would be rather similar to that of RSiMe₂OMe and that RSiMe₂O⁻ would (because of repulsion of the OMe⁻) be relatively inert, so that the observed rate constant would fall off progressively at higher base concentrations as silanolate ion was increasingly formed. Instead it appears that the R-Si bond of the anion RSiMe₂O⁻ readily undergoes a rate-determining unimolecular dissociation to Me₂Si=O and R⁻ [which rapidly react with MeOH to give $Me_2Si(OH)(OMe)$ and RH]. The observed rate constant, k, is thus made up of a contribution from this process, dependent upon the concentration of the anion, and another from RSiMe₂OMe, dependent upon the concentration of this species and that of the base. [For simplicity we treat RSiMe₂-OH, as far as its direct contribution to the observed rate is concerned, as though it were RSiMe₂OMe, on the basis of the assumptions that relatively little of the silanol is present (say 20% of the amount of RSiMe₂OMe), and that in any case the rate of its direct cleavage will not be very different from that of the methoxide.]

It was shown by u.v. spectroscopy that the related RSiMe₂-OMe with $R = PhCH_2$, which is much less readily cleaved, is *ca*. half converted into RSiMe₂O⁻ in 5% H₂O-MeOH containing 0.40 M NaOMe. (For simplicity we neglect the fact that hydroxide ion must also be present in solutions of NaOMe in H₂O-MeOH.) We assumed that for R = m-ClC₆H₄CH₂ there would be half conversion at a slightly lower base concentration, *viz.* 0.38 M (since the chloro-substituent will slightly increase the acidity of the silanol), and calculated the fraction, *r*, of the substrate present as silanolate ion at each base concentration. We estimated the value of the specific rate constant, k_8 ,



Figure 2. Plot of observed first order rate constant, k, against the base concentration for cleavage of PhC=CSiMe₂OMe at 30.0 °C in (a) MeOH (squares) and (b) 5 vol-% H₂O-MeOH (circles). The curve in case (b) is that generated by equation (2).

for cleavage of the RSiMe₂OMe in 5% H₂O-MeOH (at low base concentrations) as *ca*. 10 × 10⁻⁵ 1 mol⁻¹ s⁻¹ by applying to the value in MeOH the factor of 1.3 observed for this same solvent change with RSiMe₃. Thus we could estimate the contribution, k_{AMe} , to k from RSiMe₂OMe, given by $k_{\rm S}(1-r)$ × [NaOMe], and so derive the contribution, k_{A^-} , due to the silanolate ion.† The first-order rate constant for the decomposition of this ion is then given by k_{A^-}/r , which should be constant if our interpretations are correct, and this was approximately the case, all the values lying in the range 361— 404×10^{-6} s⁻¹ with a mean of 379 \pm 14 (standard deviation) × 10^{-6} s⁻¹. The curve shown in Figure 1 for the 5% H₂O-MeOH medium is actually that generated by use of equation (1), and

$$10^{6}k = 100(1-r)[\text{NaOMe}] + 379r$$
 (1)

the fit is very satisfactory in view of the simplifying assumptions made. (At high base concentrations the contribution of the methoxide should level off at ca. 34×10^{-6} s⁻¹ and that of the anion at ca. 379×10^{-6} s⁻¹.)

Similar behaviour was observed for the much more readily cleaved RSiMe₂OMe with R = PhC=C (Figure 2) at 30.0 °C, but much lower base concentrations are involved, and to interpret the results it has to be assumed that the RSiMe₂OMe is half converted into RSiMe₂O⁻ in 5% H₂O-MeOH containing 0.02 M base. The value of k_s for RSiMe₂OMe in this medium is estimated to be 3.3 1 mol⁻¹ s⁻¹ by applying to the value in NaOMe-MeOH the factor of 1.5 which applies in the case of RSiMe₂OMe for this change of medium. The mean value of $k_{A^-/r}$ then turns out to be 165 \pm 7 (standard deviation) s⁻¹, and the upper curve in Figure 2 is then that generated by equation (2). (The analysis implies that PhC=CSiMe₂OH is

$$k = 3.3(1-r)[\text{NaOMe}] + 165r \times 10^3$$
 (2)

ca. 20 times as acidic as PhCH₂SiMe₂OH.) The contributions from the RSiMe₂OMe and RSiMe₂O⁻ are more comparable in this case, levelling off at *ca.* 60×10^{-3} and 165×10^{-3} s⁻¹, respectively, at higher bases concentrations.

[†] The contribution from RSiMe₂OMe can be assumed to be given by $k_{\$} (1-r)[\text{NaOMe}]$ even at high base concentrations at which $k_{\$}$ in fact varies; this is because acidity function effects on $k_{\$}$ and (1-r) should approximately cancel out.

While the above experiments were in progress, we observed the operation of the new mechanism in a very different system, involving methanolysis of (Me₃Si)₃CSiPhRX species in which steric hindrance inhibits attack of nucleophiles on silicon.² It is known that the methanolyses of (Me₃Si)₃CSiPhHI and the more hindered (Me₃Si)₃CSiMe₂I are not catalysed by NaOMe,^{3,4} and that the latter undergoes solvolysis only very slowly in refluxing NaOMe-MeOH,4 and so we were not surprised to find that (Me₃Si)₃CSiPh(OMe)I did not undergo detectable reaction with 0.5 M NaOMe-MeOH in 2 h under reflux. Unexpectedly, however, (Me₃Si)₃CSiPh(OH)I (which did not react with MeOH alone in 24 h under reflux) in 0.17 M solution in 0.25 M NaOMe in MeOH was found to be completely converted into (Me₃Si)₃CSiPh(OH)(OMe) within 5 min at room temperature, as judged by the change in position of the peak for the (Me₃Si)₃C protons in the ¹H n.m.r. spectrum, and subsequent isolation of the product. This abnormal reactivity of the silanol can reasonably be attributed to the mechanism shown in Scheme 1.

Although this mechanism [an $S_{\rm N}1$ (cb) process] has not previously been observed or even postulated for silicon, there are close analogues in carbonyl chemistry (where the internal

displacement is normally in a rapid step after the rate determining process) and in phosphorus chemistry (see *e.g.*, ref. 5).

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